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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/579,800	05/19/2006	Shinji Mackawa	740756-2972	3488
22394 P. 3500 0423/2009 NIXON PEASON, LLP 401 9TH STREET, NW SUITE 900 WASHINGTON, DC 20004-2128			EXAMINER	
			PHAM, HOAI V	
			ART UNIT	PAPER NUMBER
	,		2892	
			MAIL DATE	DELIVERY MODE
			04/23/2009	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

## Application No. Applicant(s) 10/579.800 MAEKAWA ET AL. Office Action Summary Examiner Art Unit Hoai v. Pham 2892 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 29 January 2009. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-18 and 26-29 is/are pending in the application. 4a) Of the above claim(s) 19-25 is/are withdrawn from consideration. 5) Claim(s) 9-18.28 and 29 is/are allowed. 6) Claim(s) 1-8 is/are rejected. 7) Claim(s) 26-27 is/are objected to. 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are; a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abevance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some \* c) None of: Certified copies of the priority documents have been received. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). \* See the attached detailed Office action for a list of the certified copies not received. Attachment(s) 1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date. Notice of Draftsperson's Patent Drawing Review (PTO-948) 5) Notice of Informal Patent Application 3) Information Disclosure Statement(s) (PTO/SB/06)

Paper No(s)/Mail Date \_

6) Other:

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#### DETAILED ACTION

### Claim Rejections - 35 USC § 102

 The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filled in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filled in the United States before the invention by the applicant for patent, except that an international application filled under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filled in the United States only if the international application designated the United States and was published under Article 21(2) of such treatly in the English language.
- Claims 1-8 are rejected under 35 U.S.C. 102(e) as being anticipated by Maekawa et al. [US 7,365,805].

The applied reference has a common assignee with the instant application.

Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 102(e) might be overcome either by a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not the invention "by another," or by an appropriate showing under 37 CFR 1.131.

With respect to claim 1, Maekawa et al. (figs. 4-9, cols. 9-18) disclose a method for manufacturing a semiconductor device comprising:

forming a base layer (201)comprising a photocatalyst material on an insulating surface of a substrate (100), wherein the photocatalyst material is tungsten oxide: Application/Control Number: 10/579,800

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forming a first conductive film pattern (202) by discharging a conductive material containing a photosensitive material on the base laver by droplet discharging:

selectively exposing the first conductive film pattern to laser light (col. 11, lines 5-30); and

forming a second conductive film pattern (203) by developing the exposed first conductive film pattern.

With respect to claim 2, Maekawa et al. (col. 10, lines11-18) disclose the conductive material containing a photosensitive material comprises a material selected from the group consisting of Ag, Au, Cu, Ni, Al or Pt, and a compound thereof.

With respect to claims 3-4, Maekawa et al. (col. 10, lines11-18) disclose the photosensitive material (silver halide) is a negative type photosensitive material or a positive type photosensitive material.

With respect to claim 5, Maekawa et al. (figs. 4-9, cols. 9-18) disclose a method for manufacturing a semiconductor device comprising:

forming a base layer (201)comprising a photocatalyst material on an insulating surface of a substrate (100), wherein the photocatalyst material is tungsten oxide;

forming a first conductive film pattern (202) by discharging a conductive material containing a photosensitive material on the base layer by droplet discharging;

selectively exposing the first conductive film pattern to laser light (col. 11, lines 5-30);

forming a second conductive film pattern (203) having a narrower width than that of the first conductive film pattern by developing the exposed first conductive film pattern;

forming a gate insulating film (212-214) covering the second conductive film pattern; and

forming a semiconductor film (215) over the gate insulating film.

With respect to claim 6, Maekawa et al. (col. 10, lines11-18) disclose the conductive material containing a photosensitive material comprises a material selected from the group consisting of Ag, Au, Cu, Ni, Al or Pt, and a compound thereof.

With respect to claims 7-8, Maekawa et al. (col. 10, lines11-18) disclose the photosensitive material (silver halide) is a negative type photosensitive material or a positive type photosensitive material.

# Allowable Subject Matter

- 3 Claims 9-18 and 28-29 are allowed.
- 4. Claims 26-27 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

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## Response to Arguments

Applicant's arguments with respect to claims 1-8 have been considered but are moot in view of the new ground(s) of rejection.

### Conclusion

- Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).
- 7. A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.
- Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hoai v. Pham whose telephone number is 571-272-1715. The examiner can normally be reached on M-F.

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 If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Thao Xuan Le can be reached on 571-272-1708. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

10. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Hoai v Pham/ Primary Examiner, Art Unit 2892